

# P-N Junction ID

This model sets up a simple 1D benchmark of a p-n junction, or semiconductor diode, based on an example given in Ref. 1.

#### Introduction

A semiconductor diode consists of two regions with different doping: a p-type region with a dominant concentration of holes, and an n-type region with a dominant concentration of electrons. The anode contact is adjacent to the p-type region, and the cathode connects to the n-type region. Impurities that the manufacturing process adds to the semiconductor material determine each region's doping type. Donor impurities add additional electrons to the material conduction band and create n-type material. Acceptor impurities remove electrons from the valence band and create p-type material.

It is possible to derive a semiconductor model from Maxwell's equations and the Boltzmann equation for carrier transport. The three basic semiconductor equations (for a stationary problem) are given below:

$$\begin{split} \nabla \cdot (\varepsilon \nabla V) &= -q(p-n+N_D^+ - N_A^-) \\ \nabla \cdot \mathbf{J}_n &= -q R_{\mathrm{SRH}} \\ \nabla \cdot \mathbf{J}_p &= q R_{\mathrm{SRH}} \end{split}$$

where  $\varepsilon$  is the dielectric permittivity of the semiconductor, V is the electric potential, p and n are the electron and hole concentrations respectively,  $N_D^+$  and  $N_A^-$  are the concentrations of ionized donors and acceptors, respectively,  $J_n$  and  $J_p$  are the electron and hole currents, respectively, and  $R_{\rm SRH}$  is the Shockley-Read-Hall recombination rate (see below for a description, in this case this term is assumed to be the only source of electron and hole recombination).

The electron and hole currents can be expressed in terms of V, n, and p in the following manner (assuming an isothermal, nondegenerate semiconductor with a constant band structure):

$$\begin{aligned} \mathbf{J}_n &= -nq\mu_n \nabla V + \mu_n k_B T \nabla n \\ \mathbf{J}_p &= -pq\mu_p \nabla V - \mu_p k_B T \nabla n \end{aligned}$$

where  $\mu_n$  and  $\mu_p$  are the carrier mobilities,  $k_B$  is Boltzmann's constant, and T is the absolute temperature. In this model, the mobility is a complex-valued function of the temperature and the donor and acceptor concentrations, as defined in Ref. 1.

The term  $R_{\rm SRH}$  gives the rate at which electrons recombine (by a mechanism known as Shockley-Read-Hall recombination — which is often dominant in silicon). This recombination process involves traps in the forbidden band gap of the semiconductor. The recombination rate due to this mechanism is given by:

$$R_{SRH} = \frac{np-n_i^2}{\tau_p(n+n_1)+\tau_n(p+p_1)}$$

where  $n_i$  is the intrinsic carrier concentration (that is, the carrier concentration in an undoped semiconductor),  $\tau_n$  and  $\tau_p$  are the carrier lifetimes, and  $n_1$  and  $p_1$  are parameters related to the trap energy level. If the trap level is located at the middle of the band gap (which is assumed in this model), then  $n_1$  and  $p_1$  equal  $n_i$ .

# Model Definition

This model simulates the behavior of a p-n junction under reverse, equilibrium, and forward bias. The modeled junction has a length of 5  $\mu m$  and a net doping concentration of  $1\times 10^{15}$  cm $^{-3}$  for both the p- and n-doped side. A Shockley-Read-Hall recombination feature is also added to the model in order to simulate recombination usually observed in indirect band-gap semiconductor such as silicon, which is the material used in this model. The model uses the material parameters used in Ref. 1 and compares the carrier concentration profiles obtained from the computation with those obtained in the reference under different biasing conditions (–4 V, 0 V, and 0.5 V). Two different discretization methods are used to solve the model: the Finite Element Log Formation discretization and the Finite Volume discretization. The results of these two computation methods are found to be in good agreement.

#### Results and Discussion

Figure 1shows the electric potential in the junction for different biasing conditions. A good agreement is shown between the finite element, finite volume, and reference for all biasing conditions. Figure 2, Figure 4, and Figure 6 show the energy diagrams for each biasing conditions. These figures display a perfect agreement between the finite element (using streamline-diffusion stabilization) and finite volume computations. Comparing the carrier concentrations also shows a very good agreement between the reference, finite element, and finite volume computations — see Figure 3, Figure 5, and Figure 7.

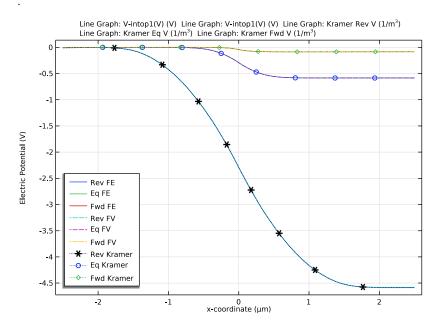


Figure 1: Electric potential obtained using the finite element (FE) and finite volume (FV) methods under different bias, that is, reverse (Rev), equilibrium (Eq), and forward (Fwd) bias. The results are compared to those calculated in Ref. 1 (Kramer)

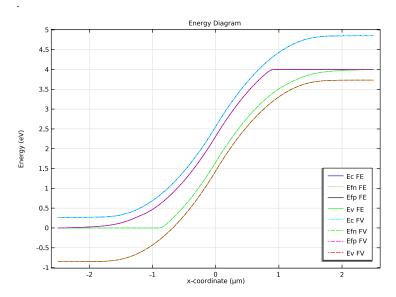


Figure 2: Energy diagram obtained using the finite element (FE) and finite volume (FV) methods under reverse bias  $(-4\ V)$ .

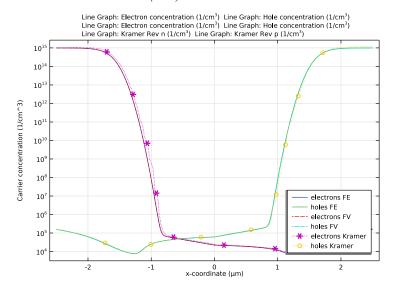


Figure 3: Electron and hole concentrations obtained using the finite element (FE) and finite volume (FV) methods under reverse bias (-4 V). The profiles are compared to those calculated in Ref. 1 (Kramer).

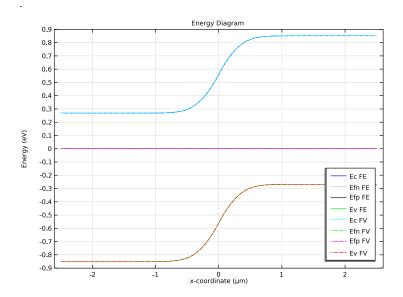


Figure 4: Energy diagram obtained using the finite element (FE) and finite volume (FV) methods at equilibrium (0 V).

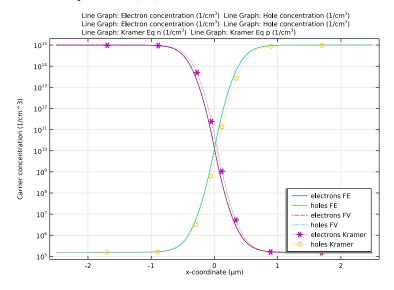


Figure 5: Electron and hole concentrations obtained using the finite element (FE) and finite volume (FV) methods at equilibrium (0 V). The profiles are compared to those calculated in Ref. 1 (Kramer).

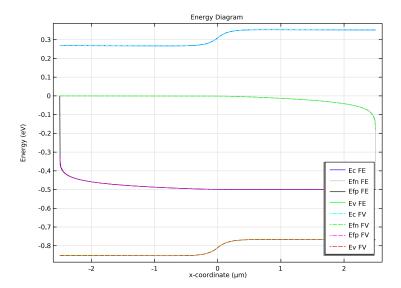


Figure 6: Energy diagram obtained using the finite element (FE) and finite volume (FV) methods under forward bias  $(0.5\ V)$ .

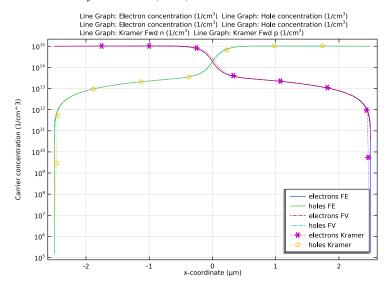


Figure 7: Electron and hole concentrations obtained using the finite element (FE) and finite volume (FV) methods under forward bias (0.5 V). The profiles are compared to those calculated in Ref. 1 (Kramer).

# Reference

1. K.M. Kramer and W.N.G. Hitchon, *Semiconductor Devices a Simulation Approach*, Prentice Hall, Upper Saddle River, NJ, 1997.

Application Library path: Semiconductor\_Module/Verification\_Examples/
pn\_junction\_1d

# Modeling Instructions

From the File menu, choose New.

#### NFW

In the New window, click Model Wizard.

#### MODEL WIZARD

- I In the Model Wizard window, click ID.
- 2 In the Select Physics tree, select Semiconductor>Semiconductor (semi).
- 3 Click Add.
- 4 Click Study.
- 5 In the Select Study tree, select General Studies>Stationary.
- 6 Click Mone.

# SEMICONDUCTOR (SEMI)

- I In the Model Builder window, under Component I (compl) click Semiconductor (semi).
- 2 In the Settings window for Semiconductor, click to expand the Discretization section.
- 3 From the Formulation list, choose Finite element, log formulation (linear shape function).

#### GEOMETRY I

- I In the Model Builder window, under Component I (compl) click Geometry I.
- 2 In the Settings window for Geometry, locate the Units section.
- 3 From the Length unit list, choose  $\mu m$ .

Interval I (iI)

I Right-click Component I (compl)>Geometry I and choose Interval.

- 2 In the Settings window for Interval, locate the Interval section.
- **3** In the table, enter the following settings:

Coordinates (µm)	
-2.5	
2.5	

# Point I (ptl)

- I In the Model Builder window, right-click Geometry I and choose Point.
- 2 In the Settings window for Point, click | Build All Objects.

#### **GLOBAL DEFINITIONS**

## Parameters I

- I In the Model Builder window, under Global Definitions click Parameters I.
- 2 In the Settings window for Parameters, locate the Parameters section.
- 3 Click Load from File.
- **4** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_parameters.txt.

#### DEFINITIONS

#### Variables 1

- I In the Home toolbar, click  $\supseteq$  Variables and choose Local Variables.
- 2 In the Settings window for Variables, locate the Variables section.
- 3 Click **Load from File**.
- **4** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_variables.txt.

# Kramer Eq V

- I In the Home toolbar, click f(x) Functions and choose Local>Interpolation.
- 2 In the Settings window for Interpolation, locate the Definition section.
- 3 In the Function name text field, type kramer\_eq\_V.
- 4 Click **Load from File**.
- **5** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_Kramer\_eq\_V.txt.

Argument	Unit
t	m

7 In the **Function** table, enter the following settings:

Function	Unit
kramer_eq_V	1/m^3

8 In the Label text field, type Kramer Eq V.

#### Kramer Fwd V

- I In the Home toolbar, click f(x) Functions and choose Local>Interpolation.
- 2 In the Settings window for Interpolation, locate the Definition section.
- 3 In the Function name text field, type kramer\_fwd\_V.
- 4 Click Load from File.
- **5** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_Kramer\_fwd\_V.txt.
- 6 Locate the Units section. In the Argument table, enter the following settings:

Argument	Unit
t	m

7 In the **Function** table, enter the following settings:

Function	Unit
kramer_fwd_V	1/m^3

8 In the Label text field, type Kramer Fwd V.

# Kramer Rev V

- I In the Home toolbar, click f(X) Functions and choose Local>Interpolation.
- 2 In the Settings window for Interpolation, locate the Definition section.
- 3 In the Function name text field, type kramer\_rev\_V.
- 4 Click Load from File.
- **5** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_Kramer\_rev\_V.txt.

Argument	Unit
t	m

7 In the **Function** table, enter the following settings:

Function	Unit
kramer_rev_V	1/m^3

8 In the Label text field, type Kramer Rev V.

## Kramer Eq n

- I In the Home toolbar, click f(x) Functions and choose Local>Interpolation.
- 2 In the Settings window for Interpolation, locate the Definition section.
- 3 Click **Load from File**.
- **4** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_Kramer\_eq\_n.txt.
- 5 In the Function name text field, type kramer\_eq\_n.
- 6 Locate the Units section. In the Argument table, enter the following settings:

Argument	Unit
t	m

7 In the **Function** table, enter the following settings:

Function	Unit
kramer_eq_n	1/m^3

8 In the Label text field, type Kramer Eq n.

#### Kramer Eq p

- I In the Home toolbar, click f(X) Functions and choose Local>Interpolation.
- 2 In the Settings window for Interpolation, locate the Definition section.
- 3 Click **Load from File**.
- **4** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_Kramer\_eq\_p.txt.
- 5 In the Function name text field, type kramer\_eq\_p.

Argument	Unit
t	m

7 In the **Function** table, enter the following settings:

Function	Unit
kramer_eq_p	1/m^3

8 In the Label text field, type Kramer Eq p.

#### Kramer Fwd n

- I In the Home toolbar, click f(x) Functions and choose Local>Interpolation.
- 2 In the Settings window for Interpolation, locate the Definition section.
- 3 In the Function name text field, type kramer\_fwd\_n.
- 4 Click **Load from File**.
- **5** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_Kramer\_fwd\_n.txt.
- 6 Locate the Units section. In the Argument table, enter the following settings:

Argument	Unit
t	m

7 In the **Function** table, enter the following settings:

Function	Unit	
kramer_fwd_n	1/m^3	

**8** In the **Label** text field, type Kramer Fwd n.

#### Kramer Fwd p

- I In the Home toolbar, click f(X) Functions and choose Local>Interpolation.
- 2 In the Settings window for Interpolation, locate the Definition section.
- 3 In the Function name text field, type kramer\_fwd\_p.
- 4 Click Load from File.
- **5** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_Kramer\_fwd\_p.txt.

Argument	Unit
t	m

7 In the Function table, enter the following settings:

Function	Unit	
kramer_fwd_p	1/m^3	

8 In the Label text field, type Kramer Fwd p.

#### Kramer Rev n

- I In the Home toolbar, click f(x) Functions and choose Local>Interpolation.
- 2 In the Settings window for Interpolation, locate the Definition section.
- 3 In the Function name text field, type kramer\_rev\_n.
- 4 Click Load from File.
- **5** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_Kramer\_rev\_n.txt.
- 6 Locate the Units section. In the Argument table, enter the following settings:

Argument	Unit
t	m

7 In the **Function** table, enter the following settings:

Function	Unit	
kramer_rev_n	1/m^3	

8 In the Label text field, type Kramer Rev n.

#### Kramer Rev p

- I In the Home toolbar, click f(X) Functions and choose Local>Interpolation.
- 2 In the Settings window for Interpolation, locate the Definition section.
- 3 Click **Load from File**.
- **4** Browse to the model's Application Libraries folder and double-click the file pn\_junction\_1d\_Kramer\_rev\_p.txt.
- 5 In the Function name text field, type kramer\_rev\_p.

Argument	Unit
t	m

7 In the **Function** table, enter the following settings:

Function	Unit	
kramer_rev_p	1/m^3	

8 In the Label text field, type Kramer Rev p.

Integration I (intopl)

- I In the Definitions toolbar, click / Nonlocal Couplings and choose Integration.
- 2 In the Settings window for Integration, locate the Source Selection section.
- 3 From the Geometric entity level list, choose Boundary.
- 4 Select Boundary 1 only.

# SEMICONDUCTOR (SEMI)

Semiconductor Material Model I

- I In the Model Builder window, under Component I (comp1)>Semiconductor (semi) click Semiconductor Material Model I.
- 2 In the Settings window for Semiconductor Material Model, locate the Model Input section.
- **3** In the T text field, type T1.
- **4** Locate the **Mobility Model** section. From the  $\mu_n$  list, choose **User defined**. In the associated text field, type mu\_n.
- **5** From the  $\mu_p$  list, choose **User defined**. In the associated text field, type mu\_p.

Trap-Assisted Recombination 1

- I In the Physics toolbar, click Domains and choose Trap-Assisted Recombination.
- 2 In the Settings window for Trap-Assisted Recombination, locate the Domain Selection section.
- 3 From the Selection list, choose All domains.

Analytic Doping Model 1

- I In the Physics toolbar, click Domains and choose Analytic Doping Model.
- 2 Select Domain 1 only.
- 3 In the Settings window for Analytic Doping Model, locate the Impurity section.

- 4 From the Impurity type list, choose Donor doping (n-type).
- **5** In the  $N_{D0}$  text field, type Nd.

# Analytic Doping Model 2

- I In the Physics toolbar, click Domains and choose Analytic Doping Model.
- 2 Select Domain 2 only.
- 3 In the Settings window for Analytic Doping Model, locate the Impurity section.
- **4** In the  $N_{A0}$  text field, type Na.

# Metal Contact I

- I In the Physics toolbar, click Boundaries and choose Metal Contact.
- 2 Select Boundary 1 only.

# Metal Contact 2

- I In the Physics toolbar, click Boundaries and choose Metal Contact.
- 2 In the Settings window for Metal Contact, locate the Terminal section.
- **3** In the  $V_0$  text field, type Va.
- 4 Select Boundary 3 only.

# MATERIALS

Material I (mat I)

- I In the Model Builder window, under Component I (compl) right-click Materials and choose Blank Material.
- 2 In the Settings window for Material, locate the Material Contents section.
- **3** In the table, enter the following settings:

Property	Variable	Value	Unit	Property group
Relative permittivity	epsilonr_iso; epsilonrii = epsilonr_iso, epsilonrij = 0	epsilonr_param	I	Basic
Band gap	Eg0	Eg0_param	٧	Semiconductor material
Electron affinity	chi0	chi0_param	٧	Semiconductor material
Effective density of states, conduction band	Nc	Nc_param	I/m³	Semiconductor material

Property	Variable	Value	Unit	Property group
Effective density of states, valence band	Nv	Nv_param	I/m³	Semiconductor material
Electron lifetime, SRH	taun	taun_param	s	Shockley-Read-Hall recombination
Hole lifetime, SRH	taup	taup_param	s	Shockley-Read-Hall recombination

#### MESH I

#### Edge 1

In the Mesh toolbar, click A Edge.



## Distribution I

- I Right-click **Edge I** and choose **Distribution**.
- 2 In the Settings window for Distribution, locate the Distribution section.
- 3 In the Number of elements text field, type 500.

Configure the first study. The finite element log formulation discretization requires the voltage applied to the device to be ramped on. This is achieved using the 'sweep' variable, which is ramped from 0 to 1 using the solver's continuation functionality. The voltage applied to the device, Va, is calculated using Va=bias\*sweep, as can be seen in the parameters table within the Definitions node. The first study will be configured to apply three different biases, with each bias being ramped from 0 V to the intended value as 'sweep' increases from 0 to 1.

#### STUDY I - FINITE ELEMENT LOG FORMULATION

- I In the Model Builder window, click Study I.
- 2 In the Settings window for Study, type Study 1 Finite Element Log Formulation in the Label text field.

## Step 1: Stationary

- I In the Model Builder window, under Study I Finite Element Log Formulation click Step 1: Stationary.
- 2 In the Settings window for Stationary, click to expand the Study Extensions section.
- 3 Select the Auxiliary sweep check box.
- 4 From the Sweep type list, choose All combinations.
- 5 Click + Add.

**6** In the table, enter the following settings:

Parameter name	Parameter value list	Parameter unit
bias (Device bias)	-4 0 0.5	V

- 7 Click + Add.
- **8** In the table, enter the following settings:

Parameter name	Parameter value list	Parameter unit
sweep (Sweep parameter for	0 1	
gradually turning on bias)		

**9** In the **Home** toolbar, click **Compute**.

# RESULTS

Energy Levels (semi)

- I In the Settings window for ID Plot Group, locate the Data section.
- 2 From the Parameter selection (bias) list, choose First.
- 3 From the Parameter selection (sweep) list, choose Last.

Conduction Band Energy Level

- I In the Model Builder window, expand the Energy Levels (semi) node, then click Conduction Band Energy Level.
- 2 In the Settings window for Line Graph, locate the x-Axis Data section.
- 3 From the Parameter list, choose Expression.
- **4** In the **Expression** text field, type x.
- **5** Click to expand the **Legends** section. In the table, enter the following settings:

Legends		
Ec	FE	

Electron Quasi-Fermi Energy Level

- I In the Model Builder window, click Electron Quasi-Fermi Energy Level.
- 2 In the Settings window for Line Graph, locate the x-Axis Data section.
- 3 From the Parameter list, choose Expression.
- 4 In the Expression text field, type x.

**5** Locate the **Legends** section. In the table, enter the following settings:

Legends Efn FE

- **6** Click to expand the **Coloring and Style** section. Find the **Line style** subsection. From the **Line** list, choose **Solid**.
- 7 From the Color list, choose Gray.

Hole Quasi-Fermi Energy Level

- I In the Model Builder window, click Hole Quasi-Fermi Energy Level.
- 2 In the Settings window for Line Graph, locate the x-Axis Data section.
- 3 From the Parameter list, choose Expression.
- 4 In the Expression text field, type x.
- 5 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Solid.
- **6** Locate the **Legends** section. In the table, enter the following settings:

**Legends**Efp FE

Valence Band Energy Level

- I In the Model Builder window, click Valence Band Energy Level.
- 2 In the Settings window for Line Graph, locate the x-Axis Data section.
- 3 From the Parameter list, choose Expression.
- 4 In the Expression text field, type x.
- **5** Locate the **Legends** section. In the table, enter the following settings:

Legends Ev FE

Energy Levels Reverse Bias

- I In the Model Builder window, click Energy Levels (semi).
- 2 In the Settings window for ID Plot Group, locate the Legend section.
- 3 From the Position list, choose Lower right.
- 4 In the Label text field, type Energy Levels Reverse Bias.

Carrier Concentrations Reverse Bias

- I In the Model Builder window, click Carrier Concentrations (semi).
- 2 In the Settings window for ID Plot Group, locate the Legend section.
- 3 From the Position list, choose Lower right.
- 4 In the Label text field, type Carrier Concentrations Reverse Bias.
- 5 Locate the Data section. From the Parameter selection (bias) list, choose First.
- 6 From the Parameter selection (sweep) list, choose Last.

# Electron Concentration

- I In the Model Builder window, expand the Carrier Concentrations Reverse Bias node, then click Electron Concentration.
- 2 In the Settings window for Line Graph, locate the x-Axis Data section.
- 3 From the Parameter list, choose Expression.
- 4 In the Expression text field, type x.
- **5** Locate the **Legends** section. In the table, enter the following settings:

# **Legends**electrons FE

#### Hole Concentration

- I In the Model Builder window, click Hole Concentration.
- 2 In the Settings window for Line Graph, locate the x-Axis Data section.
- 3 From the Parameter list, choose Expression.
- **4** In the **Expression** text field, type x.
- **5** Locate the **Legends** section. In the table, enter the following settings:

# Legends holes FE

# Line Graph I

- I In the Model Builder window, expand the Results>Electric Potential (semi) node, then click Line Graph 1.
- 2 In the Settings window for Line Graph, locate the y-Axis Data section.
- **3** In the **Expression** text field, type V-intop1(V).
- 4 Locate the x-Axis Data section. From the Parameter list, choose Expression.
- **5** In the **Expression** text field, type x.

- **6** Locate the **Legends** section. Select the **Show legends** check box.
- 7 From the Legends list, choose Manual.
- **8** In the table, enter the following settings:

# Legends Rev FE

Eq FE

Fwd FE

## Electric Potential (semi)

- I In the Model Builder window, click Electric Potential (semi).
- 2 In the Settings window for ID Plot Group, locate the Legend section.
- 3 From the Position list, choose Lower left.
- 4 Locate the Data section. From the Parameter selection (sweep) list, choose Last.

In order to compare the finite element log formulation discretization with finite volume discretization, change the discretization and add a second study to re-solve the model with the new selection.

## SEMICONDUCTOR (SEMI)

- I In the Model Builder window, under Component I (compl) click Semiconductor (semi).
- 2 In the Settings window for Semiconductor, locate the Discretization section.
- 3 From the Formulation list, choose Finite volume (constant shape function).

## ADD STUDY

- I In the Home toolbar, click Add Study to open the Add Study window.
- 2 Go to the Add Study window.
- 3 Find the Studies subsection. In the Select Study tree, select General Studies>Stationary.
- 4 Click Add Study in the window toolbar.
- 5 In the Home toolbar, click Add Study to close the Add Study window.

#### STUDY 2 - FINITE VOLUME

- I In the Model Builder window, click Study 2.
- 2 In the Settings window for Study, type Study 2 Finite Volume in the Label text field.

3 Locate the Study Settings section. Clear the Generate default plots check box.

Unlike in the previous study, the finite volume discretization does not require that the voltage be ramped up gradually. Therefore the desired values of 'Va' can be set directly in the auxiliary sweep.

# Step 1: Stationary

- I In the Model Builder window, under Study 2 Finite Volume click Step 1: Stationary.
- 2 In the Settings window for Stationary, locate the Study Extensions section.
- 3 Select the Auxiliary sweep check box.
- 4 Click + Add.
- **5** In the table, enter the following settings:

Parameter name	Parameter value list	Parameter unit
Va (Applied voltage)	-4 0 0.5	V

6 In the Home toolbar, click **Compute**.

## RESULTS

Line Graph 2

- I In the Model Builder window, under Results>Electric Potential (semi) right-click
  Line Graph I and choose Duplicate.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Dataset list, choose Study 2 Finite Volume/Solution 2 (sol2).
- 4 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dashed.
- **5** Locate the **Legends** section. In the table, enter the following settings:

Legends		
Rev	FV	
Eq F	٧	
Fwd	FV	

Line Graph 3

- I Right-click Line Graph I and choose Duplicate.
- 2 In the Settings window for Line Graph, locate the y-Axis Data section.
- 3 In the Expression text field, type knamer rev V(x).

- 4 Locate the Data section. From the Dataset list, choose Study 1 Finite Element Log Formulation/Solution 1 (sol1).
- 5 From the Parameter selection (bias) list, choose First.
- 6 From the Parameter selection (sweep) list, choose Last.
- 7 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dotted.
- 8 Find the Line markers subsection. From the Marker list, choose Cycle.
- 9 From the Positioning list, choose Interpolated.
- **10** Locate the **Legends** section. In the table, enter the following settings:

# Legends Rev Kramer

Line Graph 4

- I Right-click Line Graph 3 and choose Duplicate.
- 2 In the Settings window for Line Graph, locate the y-Axis Data section.
- 3 In the Expression text field, type  $kramer_eq_V(x)$ .
- **4** Locate the **Legends** section. In the table, enter the following settings:

# Legends Eq Kramer

Line Graph 5

- I Right-click Line Graph 4 and choose Duplicate.
- 2 In the Settings window for Line Graph, locate the y-Axis Data section.
- 3 In the Expression text field, type knamer fwd V(x).
- **4** Locate the **Legends** section. In the table, enter the following settings:

# Legends Fwd Kramer

5 In the Electric Potential (semi) toolbar, click Plot.

Conduction Band Energy Level, Electron Quasi-Fermi Energy Level, Hole Quasi-Fermi Energy Level, Valence Band Energy Level

I In the Model Builder window, under Results>Energy Levels Reverse Bias, Ctrl-click to select Conduction Band Energy Level, Electron Quasi-Fermi Energy Level, Hole Quasi-Fermi Energy Level, and Valence Band Energy Level.

2 Right-click and choose **Duplicate**.

Conduction Band Energy Level 1

- I In the Settings window for Line Graph, locate the Data section.
- 2 From the Dataset list, choose Study 2 Finite Volume/Solution 2 (sol2).
- 3 From the Parameter selection (Va) list, choose First.
- 4 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dashed.
- 5 From the Color list, choose Cyan.
- **6** Locate the **Legends** section. In the table, enter the following settings:

# **Legends**Ec FV

Electron Quasi-Fermi Energy Level I

- I In the Model Builder window, click Electron Quasi-Fermi Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Dataset list, choose Study 2 Finite Volume/Solution 2 (sol2).
- 4 From the Parameter selection (Va) list, choose First.
- 5 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dashed.
- 6 From the Color list, choose Green.
- **7** Locate the **Legends** section. In the table, enter the following settings:

# **Legends** Efn FV

Hole Quasi-Fermi Energy Level I

- I In the Model Builder window, click Hole Quasi-Fermi Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Dataset list, choose Study 2 Finite Volume/Solution 2 (sol2).
- 4 From the Parameter selection (Va) list, choose First.
- 5 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dashed.
- 6 From the Color list, choose Magenta.

7 Locate the **Legends** section. In the table, enter the following settings:

Legends Efp FV

Valence Band Energy Level 1

- I In the Model Builder window, click Valence Band Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Dataset list, choose Study 2 Finite Volume/Solution 2 (sol2).
- 4 From the Parameter selection (Va) list, choose First.
- 5 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dashed.
- 6 From the Color list, choose Red.
- 7 Locate the **Legends** section. In the table, enter the following settings:

Legends Ev FV

8 In the Energy Levels Reverse Bias toolbar, click  **Plot**.

Electron Concentration, Hole Concentration

- I In the Model Builder window, under Results>Carrier Concentrations Reverse Bias, Ctrlclick to select Electron Concentration and Hole Concentration.
- 2 Right-click and choose **Duplicate**.

Electron Concentration I

- I In the Settings window for Line Graph, locate the Data section.
- 2 From the Dataset list, choose Study 2 Finite Volume/Solution 2 (sol2).
- 3 From the Parameter selection (Va) list, choose First.
- 4 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dashed.
- **5** Locate the **Legends** section. In the table, enter the following settings:

Legends electrons FV

Hole Concentration I

I In the Model Builder window, click Hole Concentration I.

- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Dataset list, choose Study 2 Finite Volume/Solution 2 (sol2).
- 4 From the Parameter selection (Va) list, choose First.
- 5 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dashed.
- **6** Locate the **Legends** section. In the table, enter the following settings:

# Legends

holes FV

Electron Concentration 1, Hole Concentration 1

- I In the Model Builder window, under Results>Carrier Concentrations Reverse Bias, Ctrlclick to select Electron Concentration I and Hole Concentration I.
- 2 Right-click and choose **Duplicate**.

Electron Concentration 1.1

- I In the Settings window for Line Graph, locate the y-Axis Data section.
- 2 In the Expression text field, type  $kramer_rev_n(x)$ .
- 3 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dotted.
- 4 Find the Line markers subsection. From the Marker list, choose Cycle.
- 5 From the Positioning list, choose Interpolated.
- **6** Locate the **Legends** section. In the table, enter the following settings:

# Legends

electrons Kramer

Hole Concentration 1.1

- I In the Model Builder window, click Hole Concentration I.I.
- 2 In the Settings window for Line Graph, locate the y-Axis Data section.
- 3 In the Expression text field, type kramer\_rev\_p(x).
- 4 Locate the Coloring and Style section. Find the Line style subsection. From the Line list, choose Dotted.
- **5** Find the **Line markers** subsection. From the **Marker** list, choose **Cycle**.
- 6 From the Positioning list, choose Interpolated.

7 Locate the **Legends** section. In the table, enter the following settings:

Legends holes Kramer

8 In the Carrier Concentrations Reverse Bias toolbar, click Plot.

Carrier Concentrations Reverse Bias, Energy Levels Reverse Bias

- I In the Model Builder window, under Results, Ctrl-click to select Energy Levels Reverse Bias and Carrier Concentrations Reverse Bias.
- **2** Right-click and choose **Duplicate**.

Carrier Concentrations Reverse Bias 1, Energy Levels Reverse Bias 1

- In the Model Builder window, under Results, Ctrl-click to select
   Energy Levels Reverse Bias 1 and Carrier Concentrations Reverse Bias 1.
- 2 Right-click and choose **Duplicate**.

Energy Levels Equilibrium

- I In the Settings window for ID Plot Group, type Energy Levels Equilibrium in the Label text field.
- 2 Locate the Data section. From the Parameter selection (sweep) list, choose From list.
- 3 In the Parameter values (sweep) list, select 0.

Conduction Band Energy Level 1

- I In the Model Builder window, expand the Energy Levels Equilibrium node, then click Conduction Band Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose From list.
- 4 In the Parameter values (Va (V)) list, select 0.

Electron Quasi-Fermi Energy Level I

- I In the Model Builder window, click Electron Quasi-Fermi Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose From list.
- 4 In the Parameter values (Va (V)) list, select 0.

Hole Quasi-Fermi Energy Level 1

- I In the Model Builder window, click Hole Quasi-Fermi Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.

- 3 From the Parameter selection (Va) list, choose From list.
- 4 In the Parameter values (Va (V)) list, select 0.

Valence Band Energy Level 1

- I In the Model Builder window, click Valence Band Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose From list.
- 4 In the Parameter values (Va (V)) list, select 0.
- 5 In the Energy Levels Equilibrium toolbar, click Plot.

Carrier Concentrations Reverse Bias I

- I In the Model Builder window, under Results click Carrier Concentrations Reverse Bias I.
- 2 In the Settings window for ID Plot Group, locate the Data section.
- 3 From the Parameter selection (sweep) list, choose From list.
- 4 In the Parameter values (sweep) list, select 0.

Electron Concentration I

- I In the Model Builder window, expand the Carrier Concentrations Reverse Bias I node, then click Electron Concentration I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose From list.
- 4 In the Parameter values (Va (V)) list, select 0.

Hole Concentration I

- I In the Model Builder window, click Hole Concentration I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose From list.
- 4 In the Parameter values (Va (V)) list, select 0.

Electron Concentration 1.1

- I In the Model Builder window, click Electron Concentration I.I.
- 2 In the Settings window for Line Graph, locate the y-Axis Data section.
- 3 In the Expression text field, type knamer eq n(x).

Hole Concentration 1.1

- I In the Model Builder window, click Hole Concentration I.I.
- 2 In the Settings window for Line Graph, locate the y-Axis Data section.

- 3 In the Expression text field, type  $kramer_eq_p(x)$ .

Carrier Concentrations Equilibrium

- I In the Model Builder window, right-click Carrier Concentrations Reverse Bias I and choose Rename.
- 2 In the Rename ID Plot Group dialog box, type Carrier Concentrations Equilibrium in the New label text field.
- 3 Click OK.

Energy Levels Reverse Bias 1.1

- I In the Model Builder window, click Energy Levels Reverse Bias 1.1.
- 2 In the Settings window for ID Plot Group, locate the Data section.
- 3 From the Parameter selection (bias) list, choose Last.

Conduction Band Energy Level 1

- I In the Model Builder window, expand the Energy Levels Reverse Bias I.I node, then click Conduction Band Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose Last.

Electron Quasi-Fermi Energy Level I

- I In the Model Builder window, click Electron Quasi-Fermi Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose Last.

Hole Quasi-Fermi Energy Level 1

- I In the Model Builder window, click Hole Quasi-Fermi Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose Last.

Valence Band Energy Level 1

- I In the Model Builder window, click Valence Band Energy Level I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose Last.
- 4 In the Energy Levels Reverse Bias I.I toolbar, click  **Plot**.

Energy Levels Forward Bias

- I In the Model Builder window, right-click Energy Levels Reverse Bias I.I and choose
- 2 In the Rename ID Plot Group dialog box, type Energy Levels Forward Bias in the New label text field.
- 3 Click OK.

Carrier Concentrations Forward Bias

- I In the Model Builder window, under Results click Carrier Concentrations Reverse Bias 1.1.
- 2 In the Settings window for ID Plot Group, type Carrier Concentrations Forward Bias in the Label text field.
- 3 Locate the Data section. From the Parameter selection (bias) list, choose Last.

Electron Concentration I

- I In the Model Builder window, expand the Carrier Concentrations Forward Bias node, then click Electron Concentration 1.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose Last.

Hole Concentration I

- I In the Model Builder window, click Hole Concentration I.
- 2 In the Settings window for Line Graph, locate the Data section.
- 3 From the Parameter selection (Va) list, choose Last.

Electron Concentration 1.1

- I In the Model Builder window, click Electron Concentration I.I.
- 2 In the Settings window for Line Graph, locate the y-Axis Data section.
- 3 In the Expression text field, type  $kramer_fwd_n(x)$ .

Hole Concentration 1.1

- I In the Model Builder window, click Hole Concentration I.I.
- 2 In the Settings window for Line Graph, locate the y-Axis Data section.
- 3 In the Expression text field, type  $kramer_fwd_p(x)$ .
- 4 In the Carrier Concentrations Forward Bias toolbar, click Plot.